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## PATENT

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

KARSTEN WIECZOREK  
FALK GRAETSCH  
LUTZ HERRMANN

Serial No.: 10/693,024

Filed: October 24, 2003

For: TECHNIQUE FOR FORMING AN  
OXIDE/NITRIDE LAYER STACK BY  
COMPENSATING NITROGEN  
NON-UNIFORMITIES

Examiner: Eric Bric Chen

Group Art Unit: 1765

Att'y Docket: 2000.108600/DE0362

Customer No.: 23720

**RESPONSE TO OFFICE ACTION DATED JUNE 22, 2005**

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

**CERTIFICATE OF MAILING**  
37 C.F.R 1.8

I hereby certify that this correspondence is being deposited with the U.S. Postal Service with sufficient postage as First Class Mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450, on the date below:

September 21, 2005  
\_\_\_\_\_  
Date

*Mary Paul*  
\_\_\_\_\_  
Signature

This paper is submitted in response to the Office Action dated June 22, 2005, for which the three-month date for response is September 22, 2005.

No fees are believed to be due in connection with the present paper. However, should any fees be required under 37 C.F.R. §§ 1.16 to 1.21, the Director is authorized to deduct such fees from the Advanced Micro Devices, Inc. Deposit Account No. 01-0365/DE0362.<sup>1</sup>

Reconsideration of the application in view of the following amendments and remarks is respectfully requested.

<sup>1</sup> In the event the monies in that account are insufficient, the Director is authorized to withdraw funds from Williams, Morgan & Amerson, P.C. Deposit Account No. 50-0786/2000.108600.